

EASTSearch History

EASTSearch History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
I1	19074	nano-scale nanoscale (nano near5 scale)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 15:43
I2	14491	1 and (substrate wafer)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 15:44
I3	71	2 and (lateral\$3 near5 grown)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 15:44
I4	17	3 and (post pedestal bump stud)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 15:49
I6	44401	nano-scale nanoscale (nano near5 scale) nano	EHS; EPO; JPO; DERWENT; IHM_TDB	OR	ON	2010/03/03 15:54
I7	9898	6 and (substrate wafer)	EHS; EPO; JPO; DERWENT; IHM_TDB	OR	ON	2010/03/03 15:54
I8	6	7 and (lateral\$3 near5 grown)	EHS; EPO; JPO; DERWENT; IHM_TDB	OR	ON	2010/03/03 15:54
I9	2	((multi-period) (multi near5 period)) same edge same lithography	EHS; EPO; JPO; DERWENT; IHM_TDB	OR	ON	2010/03/03 16:07
I10	2	((multi-period) (multi near5 period)) same edge same lithography	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 16:09
I11	1376663	(post pedestal bump stud)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 16:12
I12	323450	11 and (substrate wafer)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 16:12
I13	453	12 and (lateral\$3 near5 grown)	US_PGPUB; USPAT; USOCR	OR	ON	2010/03/03 16:12

3/3/10 5:00:12 PM

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